

Zurich Research Laboratory

#### Hybrid Photonic Nano-Structures for Lasing and Switching Applications

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June 28, 2006

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## **Optical Interconnect Hierarchy**

	WAN, MAN-level Internet, GRID	Lab & Campus-I LAN, SA	System-leve evel intra-rack & AN rack-to-rack	el Board-level module-to- module	module-leve chip-to-chip	<b>I Chip-level</b> on-chip
Distances	Multi-km	10-2,000 m	0.3-1 m	0.1-0.3 m	5-100 mm	0.1-10 mm
# Lines	1s	1s-10s	100s	1000s	10,000s	100,000s
Technologies	Internet protocol, SONET, ATM	LAN/SAN Standards (Ethernet, InfiniBand, Fibre Channel)	Design-specific system buses, new standards (InfiniBand)	Design-specific, some standards (PCI/PCI-X/3GIO)	Design- specific	Design- specific
Optics Use	Ubiquitous since 80s or early 90s	Common since late 90s: Fiber standards in Enet, IB, FC	Coming in 2006-2010, with investment	Possibly cost-effective vs. copper in 2010-2015	Later	Even later, if ever
			The Next	Steps	The Fu	uture

Hybrid Photonic Nano-Structures for Lasing and Switching Applications

#### Outline

Organic photonic crystal lasers

Laser structures with TiO<sub>2</sub> feedback layer

Interferometrically Defined Laser Structures

All-optical switching in organic micro-cavities

Cavity pump-and-probe measurements

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#### **Motivation**

#### Why organic photonic crystal lasers?

- Potentially cheap alternative to conventional edgeemitting and VCSEL lasers
- Broad gain spectrum
- Flexible wavelength selection
- Possibility to integrate into optical integrated circuits



#### Distributed Feedback in a 2D Grating / Photonic Crystal

First order: Emission in-plane

Second order: Emission in-plane and/or *directional* vertical emission



#### **IBM**

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#### Enhanced coupling in distributed feedback structures

Photonic crystal structures featuring a *TiO<sub>2</sub> layer* enhancing the feedback

- Higher index contrast than with a SiO<sub>2</sub> polymer interface
- Larger confinement in the waveguide





 Depositing the TiO<sub>2</sub> using sputtering Ti in O<sub>2</sub>





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- Depositing the Chrome etchmask using sputtering





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- Etching the TiO<sub>2</sub> using RIE





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- Etching the TiO<sub>2</sub> using RIE
- Spin-coating of the gain material





#### Characterization – Chip layout and material properties

 Devices are photonic crystal pads of ~ 100µm x 100µm down to 15µm x 15µm

Easily deposited using spin-coating

Gain maximum around 494nm





#### Lasing of 2D Photonic Crystals Structures



#### **Comparison with Band Structure Calculations**





#### Lasing Threshold of 2D Photonic Crystals Structures





#### Experimental band-diagram mapping below threshold



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### Interferometrically Defined Laser Structures

- Direct structuring of the gain material using Almaden Research Center's Laser Interferometer Lithography setup
- Advantages:
  - Relatively easy fabrication
  - High index contrast air – polymer
  - $\rightarrow$  Very regular periods
- Disadvantages:
  - Low index of the waveguide material
  - → Hard to control hole dimensions



#### Stimulated emission from Interferometrically Structured Samples



#### Holographically fabricated structures

Resist doped with a laser dye is structured using holography – Rods of resist



#### Lasing of Interferometrically Defined Structures



sample from 23/11/2004 (email John) site number "1



#### Band-Diagram Theory & Experiment



#### R.Harbers et al, APL, in press



#### Summary

- Distributed feedback through photonic crystals fabricated in TiO2 or in photo-resist
- The lasing threshold can be lowered by incorporating a high index TiO<sub>2</sub> layer
- Leads to smaller devices
- Next step: Electrically pumped organic lasers

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#### **All-Optical Switch**



### Fabrication Technology for Hybrid Cavities

- Sputtering of dielectric  $\lambda/4$  mirror stacks, for example Si/SiO<sub>2</sub> (infrared), or TiO<sub>2</sub>/SiO<sub>2</sub> (visible)
- spin coating, thermal deposition of organic thin films
- Room temperature process works with most materials



Critical parameters:  $\rightarrow$  Reproducible thickness of films  $\rightarrow$  Quality of high-index films

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#### Cavity Pump & Probe, Concept





#### Femtosecond Pump & Probe Setup



#### Femto-Second Pump & Probe technique

Laser spectrum much wider than cavity transmission



Cavity is always exposed to the same laser field!

#### Femtosecond Pump & Probe, Example Signals



#### Numerical Simulations Confirm Experimental Behavior

# differential transmission

1.29 (a) 0.6 1.28 (%) 0.4 1.27 5 wavelength  $\lambda_0$  ( $\mu$ m) differential transmission 0.2 1.26 -1.5 -1 -0.5 0.5 1.5 0 1 0 1.29 - (b) -0.2 1.28 -0.4 1.27 -0.6 1.26 -1.5 -1 -0.5 0.5 1.5 0 1 delay  $\tau$  (ps)

assume instantaneous nonlinearity:

only nonlinear refraction  $n_2$ 

only nonlinear absorption  $\alpha_2$ 

#### Femtosecond Pump & Probe, Example Fits



Excellent agreement with simulation:  $\Rightarrow$  Nonlinearity in C<sub>60</sub> is instantaneous

#### All-Optical Switching: Figures of Merit

linear absorption

nonlinear absorption

$$W \quad \frac{n_2 I}{\alpha \ \lambda} \qquad \qquad T \quad \frac{\alpha_2 \lambda}{n_2}$$

condition for bistability:

 $W \quad 1 \qquad \qquad T \quad 1$ 

intensity dependent:  $\rightarrow$  can be fulfilled through device optimization/intensity

independent of intensity:  $\rightarrow$  a true material constraint!



#### **Obtained Material Parameters**

(Infrared wavelength range 1300-1400nm)

Material	<b>n<sub>2</sub></b> (cm²/TW)	$\alpha_2$ (cm/GW)	Figure of merit <b>T</b>
C <sub>60</sub>	0.06	0.8	1.6
C <sub>70</sub>	0.04	0.5	1.75
MEH-PPV	0.1	10	12
Si	0.015	1.45	12
C <sub>60</sub> -PU	< 0.006	-	-

so far:  $C_{60}$  is the most promising material

"exotic" materials did not meet expectations



#### Summary and Conclusion

- Pump & probe measurements on Fabry-Perot micro-cavities
- Reliable characterization of nonlinear materials for all-optical switching
- Still missing: suitable nonlinear organic material
- Without nonlinear materials with much larger n<sub>2</sub> (10-100x) and good figure-of-merit T no integrated devices are feasible



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